









Power cables with aluminium conductor, XLPE-insulated, lead-sheathed, with outer sheath of polyethylene

Technical cable requirements correspond to IEC 62067

Cables are used for laying:

- · in places, where small mechanical impacts on cable are possible, including tensile forces
- in soil (trenches) with high corrosiveness
- · in damp, partially flooded premises
- in ground with high humidity
- · in wetlands
- · in non-navigable waters
- in the air, including cable structures, if provided the additional fire protection

It is possible to manufacture cables with extruded semiconductor layer along outer sheath.

Order entry example:

АПвСП-П-220 1x400/95 ТУ У 31.3-00214534-061:2008

An extruded semiconductor layer along outer sheath ensures the correct testing of cable line with sections of underground laying in polymer pipes.

It is possible to manufacture cables with an integrated fiber-optic module.

Order entry example:

АПвСП-220 1х400/95 (ОМ) ТУ У 31.3-00214534-061:2008

In conjunction with the DTS system, the integrated fiber-optic module can act as a distributed cable line temperature sensor.

It is possible to manufacture cable with sealed conductor.

Order entry example:

АПвСП-220 1х400/95 (г) ТУ У 31.3-00214534-061:2008







## АПвСП-220 1х400 ТУ У 31.3-00214534-061:2008

Power cables with aluminium conductor, XLPE-insulated, lead-sheathed, with outer sheath of polyethylene

### **TECHNICAL SPECIFICATIONS**

Rated voltage	kV	220
Maximum voltage	kV	252
Conductor rated area	mm²	400
Sheath thikness	mm	3.2
Partial discharge factor for rated voltage, not more than	рС	6
Permissible short circuit current across the screen	kA	19.90
Maximum permissible short-circuit current in core	kA	37.6
Permissible continious current rating by aerial laying *		
in trefoil formation with double-side screen earthing	Α	642
in trefoil formation with single-side screen earthing or	Α	658
cross screen earthing		
plane with double-side screen earthing	Α	679
plane with single-side screen earthing or cross screen	Α	743
earthing		
Permissible continious current rating by burial *		
in trefoil formation with double-side screen earthing	Α	504
in trefoil formation with single-side screen earthing or	Α	523
cross screen earthing		
plane with double-side screen earthing	Α	485
plane with single-side screen earthing or cross screen	Α	547
earthing		
Maximum permissible conductor temperature		
Continious	°C	+90
in emergency operation	°C	+130
at short circuit	°C	+250
Operating temperature range	°C	-60 +50
Minimum bending radius by laying	mm	2250
Rated outer diameter of the cable (for reference) **	mm	90
Cable weight (approximate)	kg/km	16120
Mata	-	

#### Notes:

When ordering it is neccesary to agree the factory length of the product with the manufacturer

<sup>\*</sup> Long permissible current loads are calculated for the following conditions: conductor temperature 90 °C, air temperature 30 °C, soil temperature 20 °C, load factor 1.0, thermal resistivity of soil 1.0 °K•m/W, laying depth in the ground 1.5 m, while laying in flat formation the distance between cables in clear is equal to the cable diameter, while laying in trefoil formation cables are laid side by side

<sup>\*\*</sup> The external diameter may differ from the rated up to  $\pm$  10 %



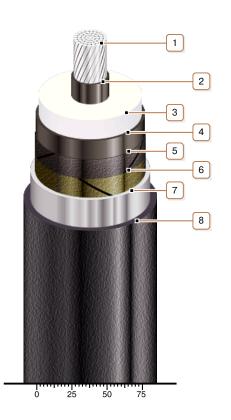




7, Autogennaya Str., Kharkov, 61099, Ukraine. Phone: (+38-057) 728-1244, 728-1241. Fax: (+38-057) 728-1243, (+38-0572) 946-830 E-mail: market@yuzhcable.com.ua

# АПвСП-220 1х400 ТУ У 31.3-00214534-061:2008

Power cables with aluminium conductor, XLPE-insulated, lead-sheathed, with outer sheath of polyethylene



### **CONSTRUCTION**

- 1. Aluminium multiwire compacted conductor
  Note: It is possible to manufacture cable with sealed conductor.
- 2. Inner extruded semiconducting layer
- 3. XLPE insulation
- 4. Outer extruded semiconducting layer
- 5. Lapping layer of semiconductive swellable tape
- 6. Lapping layer of semiconductive tape
- 7. Lead sheath
- 8. Outer sheath of polyethylene or polyethylene copolymer

Note: It is possible to manufacture cable with extruded semiconductor layer along outer sheath